

100-209498
RECEIVED CONTINUATION OF JUL 2000
PATENT

PATENT

For: SUBSTRATE PROCESSING APPARATUS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Pursuant to the duty of disclosure under 37 C.F.R. 1.56, Applicants are enclosing an Information Disclosure Citation Form (PTO-1449) which lists the documents noted in the International Search Report (ISR) filed herewith. According to the search report, U.S. Patent No. 6,736,930 is a family member of JP 2000-2773508, and U.S. Patent No. 5,627,435 is a family member of JP7-73994. Copies of the non-U.S. cited documents are enclosed.

It is respectfully requested that the cited documents be considered by the Examiner in the above-identified patent application and that the cited documents be made officially of record therein. It is further requested that a listing of the same appear on the face of any patent which may issue from this application.

By:

July 7, 2006

10/20/2006 PTO 07 JUL 2006

FORM PTO-1449 INFORMATION DISCLOSURE STATEMENT	ATTY. DOCKET 033082M335	SERIAL NO. To Be Assigned 10/20/2006
	APPLICANT: Toshihisa Nozawa, et al.	
	FILING DATE Herewith	GROUP ART UNIT To Be Assigned

U.S. PATENT DOCUMENTS

*Examiner's Initials		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE, IF APPROPRIATE
	AA	6,736,930	5/18/04	Hongoh			
	AB	5,627,435	5/6/97	Jansen, et al.			
	AC						
	AD						
	AE						
	AF						
	AG						

FOREIGN PATENT DOCUMENTS

*Examiner's Initials		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION YES NO	
	AH	2-55292	2/23/90	Japan			Abstract	
	AI	2001-156047	6/8/01	Japan			Abstract	
	AJ	2003-174016	6/20/03	Japan			Abstract	
	AK	7-73994	3/17/95	Japan			Abstract	
	AL	2000-277508	10/6/00	Japan			Abstract	
	AM	2004-127994	4/22/04	Japan			Abstract	
	AN							
	AO							
	AP							

OTHER INFORMATION (Including Author, Title, Date, Pertinent Pages, Etc.)

	AQ	
	AR	
	AS	

EXAMINER:	DATE CONSIDERED:
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.